

Docket No.: 060188-0658

## **PATENT**

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Customer Number: 20277

Masashi HAMANAKA, et al.

Confirmation Number: 8488

Application No.: 10/671,502

Group Art Unit: 3723

Filed: September 29, 2003

Examiner: RACHUBA, MAURINA T

For: POLISHING METHOD FOR SEMICONDUCTOR DEVICE, METHOD FOR FABRICATING SEMICONDUCTOR DEVICE AND POLISHING SYSTEM

## INFORMATION DISCLOSURE STATEMENT

Mail Stop RCE Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the document listed on the attached form PTO-1449. It is respectfully requested that the document be expressly considered during the prosecution of this application, and that the document be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

# 10/671,502

Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

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SHEET 1 OF 1

#### INFORMATION DISCLOSURE SERIAL NO. ATTY. DOCKET NO. 10/671,502 060188-0658 CITATION IN AN **APPLICATION** APPLICANT Masashi HAMANAKA, et al. GROUP FILING DATE (PTO-1449) September 29, 3723 2003 **U.S. PATENT DOCUMENTS EXAMINER'S** Pages, Columns, Lines, Where Document Number **Publication Date** Name of Patentee or Applicant of Cited CITE INITIALS MM-DD-YYYY Relevant Passages or Relevant NO Document Number-Kind Code2 (if known) Figures Appear ับร US US US UŠ UŞ US US US US US US US FOREIGN PATENT DOCUMENTS **EXAMINER'S** Foreign Patent Document **Publication Date** Name of Patentee or Pages, Columns, Lines Translation INITIALS Applicant of Cited Document Where Relevant Country Code3-Number 4-Kind Codes (if known) MM-DD-YYYY CITE Yes No Figures Appear NO. SUMITOMO METAL IND JAPAN (w/ JP 11-347940 A 12/21/1999 LTD English abstract) OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.) Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, EXAMINER'S INITIALS journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where CITE published. DATE CONSIDERED **EXAMINER**

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